

Docket No.: 57454-178

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Shoichiro NAKAZAWA, et al.

Serial No.: 09/915,567

Group Art Unit: 2822

Filed: July 27, 2001

Examiner: I.M. Soward

For: METHOD OF MANUFACTURING A SEMICONDUCTOR DEVICE (AS AMENDED)

REQUEST FOR RECONSIDERATION

Mail Stop Non-Fee Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

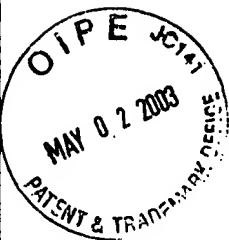
Reconsideration of the rejection under 35 U.S.C. §103 imposed in the Office

Action dated February 4, 2003 is solicited in light of the following remarks.

REMARKS

Claims 7 through 11 were rejected under 35 U.S.C. §103 for obviousness predicted upon the acknowledged prior art (Figs. 15 through 17) in view of Saitoo et al.

In the statement of the rejection, the Examiner concluded that one having ordinary skill in the art would have been motivated to modify the acknowledged prior art device by providing a short circuit preventing film in view of Saitoo et al., noting films 28 in



9/ Reconc.
JLQ3
A. Webb

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